

Shin-Etsu Synthetic Quartz

Synthetic Quartz Glass Substrates

VIOSIL-SQ (For General Application)

VIOSIL-SX (For High Temperature Application)

ShinEtsu’s VIOSIL Quartz Glass products have many advantageous characteristics as described below. Applications include photomask substrates in the semiconductor industry, poly-Si-TFT substrates for LCDs, micro lens substrates for LCDs and fiber optics, substrates for high frequency (RF) applications, microfluidic substrates, Nano-Imprint Templates, and DNA chip substrates. VIOSIL-SQ is made of a standard grade material, while VIOSIL-SX is made of a material with higher heat resistance.



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1 Features

- Purity: high purity completely eliminates contamination.
- Chemical resistance: high stability against a variety of solvents.
- Heat resistance: high dimensional stability over a wide temperature range.
- Transparency: high transmissivity over a wide range of wavelengths from UV to IR.
- Fluorescence: no fluorescence over a wide range of wavelengths from UV to IR.
- Dielectric properties: low dielectric loss even at GHz frequencies.
- Surface: high flatness, high uniformity of thickness and smooth surface, thanks to techniques developed for photomask substrates used in LSI manufacturing.

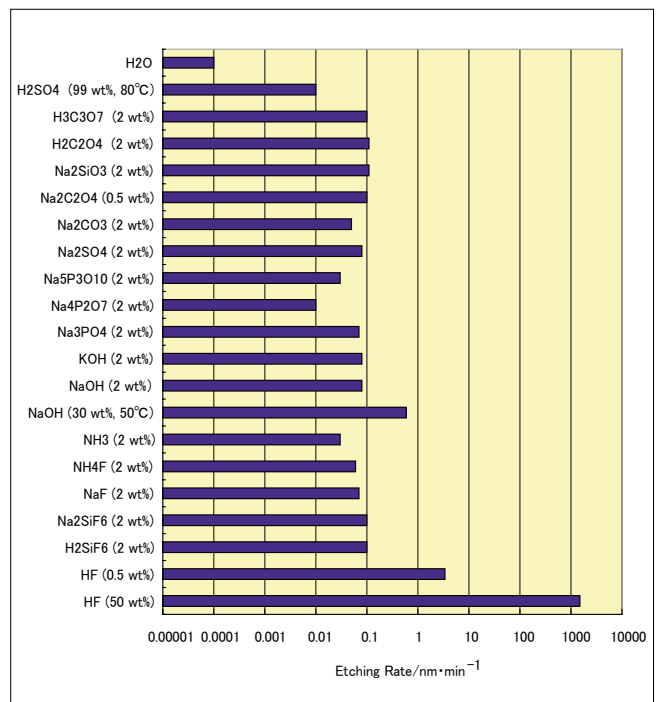
2 Physical Characteristic

Purity

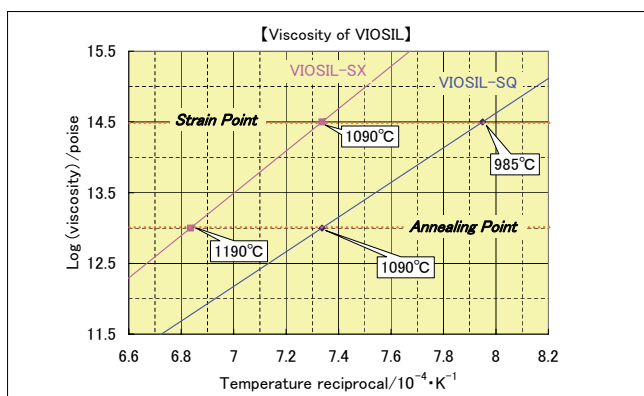
Elements	Impurities/ppb			Method of analysis
	SQ	SX	Fused quartz (natural)	
Li	< 1	< 1	700	A
Na	< 1	< 1	1000	A
Mg	< 1	< 1	200	A
Al	< 1	< 1	18000	A
K	< 1	< 1	800	A
Ca	< 1	< 1	800	A
Ti	< 1	< 1	800	A
V	< 1	< 1		A
Cr	< 1	< 1	1000	A
Mn	< 1	< 1		A
Fe	< 1	< 1	800	A
Co	< 1	< 1		A
Ni	< 1	< 1	100	A
Cu	< 1	< 1	70	A
Zn	< 1	< 1		A
Ge	< 1	< 1		A
As	< 0.1	< 0.1	0.2	C
Zr	< 1	< 1		A
Mo	< 1	< 1		A
Cd	< 1	< 1		A
Sn	< 1	< 1		A
Sb	< 1	< 1		A
Pb	< 1	< 1		A
B	< 1	< 1	100	B
P	< 1	< 1	100	B
U	< 0.1	< 0.1	0.3	C

A : Induced coupled plasma mass spectroscopy
 B : Induced coupled plasma emission spectroscopy
 C : Radioactive analysis

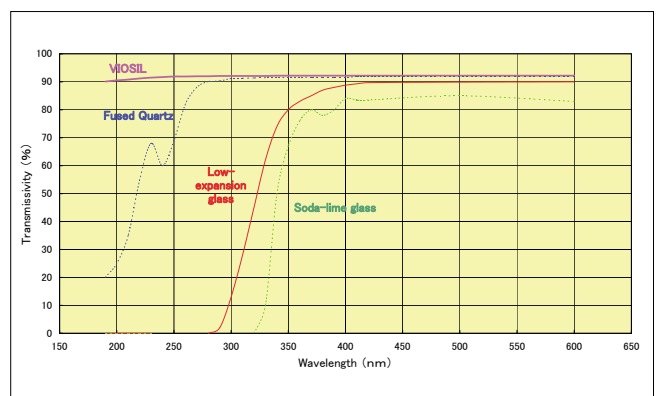
Chemical Durability



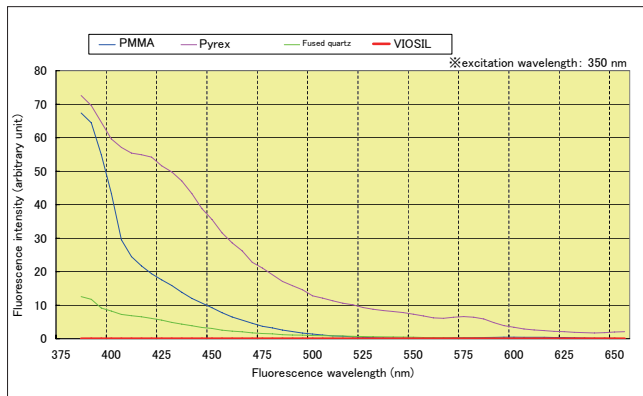
Heat Resistance



Optical Transmission



Fluorescent Intensity



Dielectric Properties

【Dielectric Properties of synthetic quartz glass VIOSIL】

(20°C)

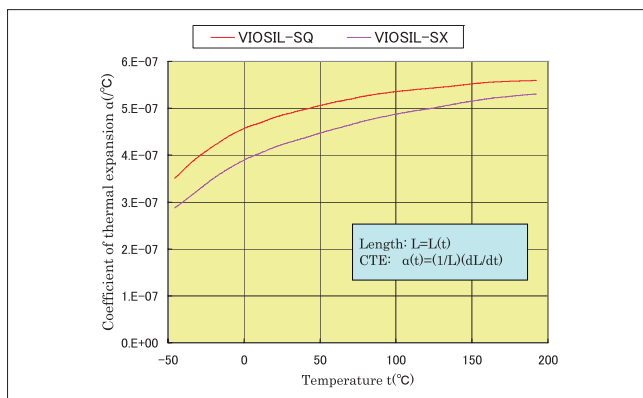
Frequency	1 MHz	100 MHz	1 GHz	30 GHz	60 GHz
Dielectric constant (ϵ_r)	3.9	3.9	3.9	3.9	3.9
Dielectric loss ($\tan \delta$)	$< 1 \times 10^{-4}$	$< 1 \times 10^{-4}$	$< 1 \times 10^{-4}$	4×10^{-4}	7×10^{-4}

【Dielectric Properties of other materials (examples)】

Material	Sodalime glass		Pyrex		Mica
Frequency	100 Hz	1 MHz	100 Hz	1 MHz	1 MHz
Dielectric constant (ϵ_r)	8.3	6.9	4.8	4.6	7
Dielectric loss ($\tan \delta$)	7.8×10^{-2}	1.0×10^{-2}	1.3×10^{-2}	0.46×10^{-2}	2×10^{-4}

3 Miscellaneous Properties

Thermal Expansion

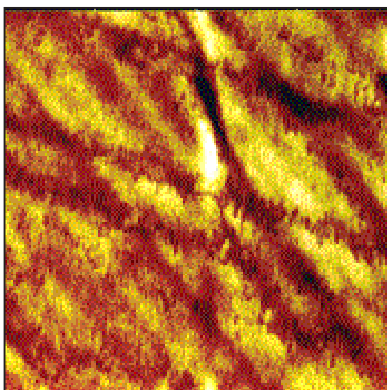


Mechanical Properties

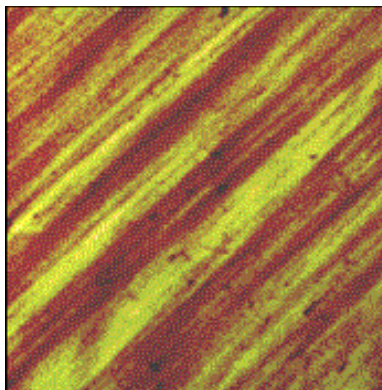
Mechanical Properties	unit	VIOSIL
specific gravity (ρ)	g/cm^3	2.202
Poisson's ratio (σ)		0.17
Young's modulus (E)	kg/mm^2	7380
shear modulus (G)	kg/mm^2	3150
Vicker's hardness (Hv)	kg/mm^2	784

4 Surface Roughness

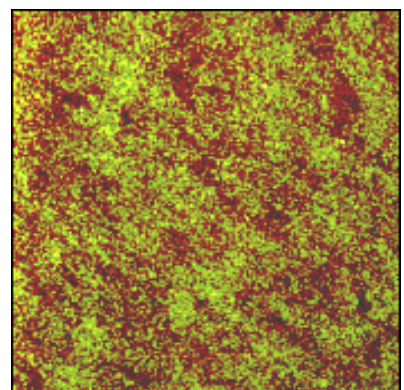
P-Grade ($R_a \leq 1.0 \text{ nm}$)



W,M-Grade ($R_a \leq 0.3 \text{ nm}$)



S-Grade ($R_a \leq 0.2 \text{ nm}$)



Measured with AFM (Atomic Force Microscope), Size : $1 \mu\text{m}^2$ area.

5 Size List

Our integrated production line incorporates all steps from the production of synthetic quartz to cutting and polishing of substrates. We can also provide substrates in sizes and specifications other than those listed below. Feel free to contact us with any requests.

1. Slide Glass Size/Square Type

Material	Product Name	Diameter (mm)	Thickness (mm)
SQ or SX	VIOSIL-SG1A	$(25.4 \times 76.2) \pm 0.1$	1.0 ± 0.02
SQ or SX	VIOSIL-SG1B	$(25.4 \times 76.2) \pm 0.1$	0.6 ± 0.02
SQ or SX	VIOSIL-SG1C	$(25.4 \times 76.2) \pm 0.1$	0.2 ± 0.02
SQ or SX	VIOSIL-SG2A	$(25.0 \times 75.0) \pm 0.1$	1.0 ± 0.02
SQ or SX	VIOSIL-SG2B	$(25.0 \times 75.0) \pm 0.1$	0.6 ± 0.02
SQ or SX	VIOSIL-SG2C	$(25.0 \times 75.0) \pm 0.1$	0.2 ± 0.02

2. Wafer Size/Circle Type

Material	Product Name	Diameter (mm)	Thickness (mm)	OF or Notch (mm)	Edge (mm)
SQ or SX	3W525WR/SX3W525WE	76.20 ± 0.25	0.525 ± 0.020	22.5 ± 2.0	0.35 ± 0.10
SQ or SX	3W1000WR/SX3W1000WR	76.20 ± 0.25	1.000 ± 0.020	22.5 ± 2.0	0.80 ± 0.10
SQ or SX	4W525WR/SX4W525WE	100.00 ± 0.25	0.525 ± 0.020	32.5 ± 2.0	0.35 ± 0.10
SQ or SX	4W1000WR/SX4W1000WE	100.00 ± 0.25	1.000 ± 0.020	32.5 ± 2.0	0.80 ± 0.10
SQ	5W550WR	125.00 ± 0.25	0.550 ± 0.020	42.5 ± 2.0	0.35 ± 0.10
SQ	5W625WR	125.00 ± 0.25	0.625 ± 0.020	42.5 ± 2.0	0.35 ± 0.10
SQ or SX	6W625WE/SX6W625WE	150.00 ± 0.25	0.625 ± 0.020	47.5 ± 2.0	0.35 ± 0.10
SQ or SX	6W675WE/SX6W675WE	150.00 ± 0.25	0.675 ± 0.020	57.5 ± 2.0	0.35 ± 0.10
SX	SX6W800WE	150.00 ± 0.25	0.800 ± 0.020	47.5 ± 2.0	0.35 ± 0.10
SQ	6W1100WR	150.00 ± 0.25	1.100 ± 0.020	47.5 ± 2.0	0.80 ± 0.10
SQ or SX	8W725WEY/SX8W725WEY	200.00 ± 0.25	0.725 ± 0.020	Notch	0.50 ± 0.10
SQ or SX	8W800WE/SX8W800WE	200.00 ± 0.25	0.800 ± 0.020	57.5 ± 2.0	0.50 ± 0.10
SQ or SX	12W1200WE/SX12W1200WE	300.00 ± 0.25	1.200 ± 0.020	Notch	0.85 ± 0.10


Notch = Angle : $90^\circ + 5^\circ - 1^\circ$, Depth : $1 \text{ mm} + 0.25, -0.00 \text{ mm}$ (Based on SEMI standard).

3. Size of Synthetic Quartz Glass for LSI Photomask Substrates

Product Name	Diameter		Thickness		Flatness
	Size	Tolerance	Size	Tolerance	Front Side
	mm	mm	mm	mm	um
SMS2506E5	63.1×63.1	±0.2	1.50	±0.10	5
SMS3006E5	75.8×75.8	±0.2	1.50	±0.10	5
SMS4006E2C	101.2×101.2	±0.2	1.50	±0.10	2
SMS4009E2C	101.2×101.2	±0.2	2.30	±0.10	2
SMS5009E5	126.6×126.6	±0.2	2.30	±0.10	5
SMS6009E5	152.0×152.0	±0.2	2.30	±0.10	5
SMS6012E2C	152.0×152.0	±0.2	3.05	±0.10	2
SMS6015E2C	152.0×152.0	±0.2	3.80	±0.10	2
SMS6025E2	152.0×152.0	±0.2	6.35	±0.10	2
SMS7012E2C	177.4×177.4	±0.2	3.05	±0.10	2
SMS7015E2C	177.4×177.4	±0.2	3.80	±0.10	2
SMS7Q15E2	184.15×184.15	±0.2	3.80	±0.10	2
SMS8009E10	200.0×200.0	±0.2	2.30	±0.10	10
SMS8012E10	200.0×200.0	±0.2	3.05	±0.10	10
SMS9025E10	228.2×228.2	±0.2	6.35	±0.10	10
SMS1420E10	355.2×355.2	±0.2	5.10	±0.10	10
SZS5009E5	126.6×126.6	±0.2	2.30	±0.10	5
SZS5018E5	126.6×126.6	±0.2	4.60	±0.10	5
SZS6025E2	152.0×152.0	±0.2	6.35	±0.10	2
SZS7012E10	177.4×177.4	±0.2	3.05	±0.10	10
SZS8009E10	200.0×200.0	±0.2	2.30	±0.10	10
SZS8012E10	200.0×200.0	±0.2	3.05	±0.10	10

4. Size of Synthetic Quartz Glass for LCD Photomask Substrates

Product Name	Diameter		Thickness		Flatness
	Size	Tolerance	Size	Tolerance	Front Side
	mm	mm	mm	mm	um
M228228Z20	228.6×228.6	±0.3	3	±0.2	20
M228228A10	228.6×228.6	±0.3	5	±0.2	10
S3345A10	330×450	±0.3	5	±0.2	10
S3745A20	370×450	±0.3	5	±0.2	10
S3961B20	390×610	±0.3	6	±0.2	20
S4252A20	420×520	±0.3	5	±0.2	20
S4253A20	420×530	±0.3	5	±0.2	20
S4353A20	430×530	±0.3	5	±0.2	20
S4452A20	440×520	±0.3	5	±0.2	20
S4555A20	450×550	±0.3	5	±0.2	20
S450554A20	450×554	±0.3	5	±0.2	20
S4657A20	460×570	±0.3	5	±0.2	20
S4757A20	470×570	±0.3	5	±0.2	20
S4959A20	490×590	±0.3	5	±0.2	20
S508609A30	508×609	±0.3	5	±0.2	30
S5075D20	500×750	±0.3	8	±0.2	20
S5261F20P	520×610	±0.3	10	±0.2	20
S5280F10P	520×800	±0.3	10	±0.2	10
S6272D30P	620×720	±0.3	8	±0.2	30
S6575D30P	650×750	±0.3	8	±0.2	30
S7080D30P	700×800	±0.3	8	±0.2	30
SLC7080D30	700×800	±0.3	8	±0.2	30
S8092D30P	800×920	±0.3	8	±0.2	30
SLC8092D30	800×920	±0.3	8	±0.2	30
SLC8092F30	800×920	±0.3	10	±0.2	30
S8092F20/L10	800×920	±0.3	10	±0.2	20
S8096D30P	800×960	±0.3	8	±0.2	30
S70110F30P	700×1100	±0.3	10	±0.2	30
S85100F20P	850×1000	±0.3	10	±0.2	20
SLC85100F30	850×1000	±0.3	10	±0.2	30
S85120F20P	850×1200	±0.3	10	±0.2	20
SLC85120F30	850×1200	±0.3	10	±0.2	30
S85135E20/L10	850×1350	±0.3	9	±0.2	20
S85140F20P	850×1400	±0.3	10	±0.2	20
SLC85140F30	850×1400	±0.3	10	±0.2	30
S122140J20/L10	1220×1400	±0.3	13	±0.2	20
SLC122140J30	1220×1400	±0.3	13	±0.2	30

*S : NORMAL CHAMFER 

*SLC : FRONT LARGE CHAMFER 



Shin-Etsu Chemical Co., Ltd.

Advanced Materials Division

6-1 Ohtemachi 2-chome, Chiyoda-ku, Tokyo, Japan

TEL.+81-(0)3-3246-5222 FAX.+81-(0)3-3246-6839 E-mail: r_nakata@shinetsu.jp